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(54) Title: POLYSILAZANE, SILICEOUS FILM-FORMING COMPOSITION COMPRISING THE SAME, AND METHOD FOR
PRODUCING SILICEOUS FILM USING THE SAME

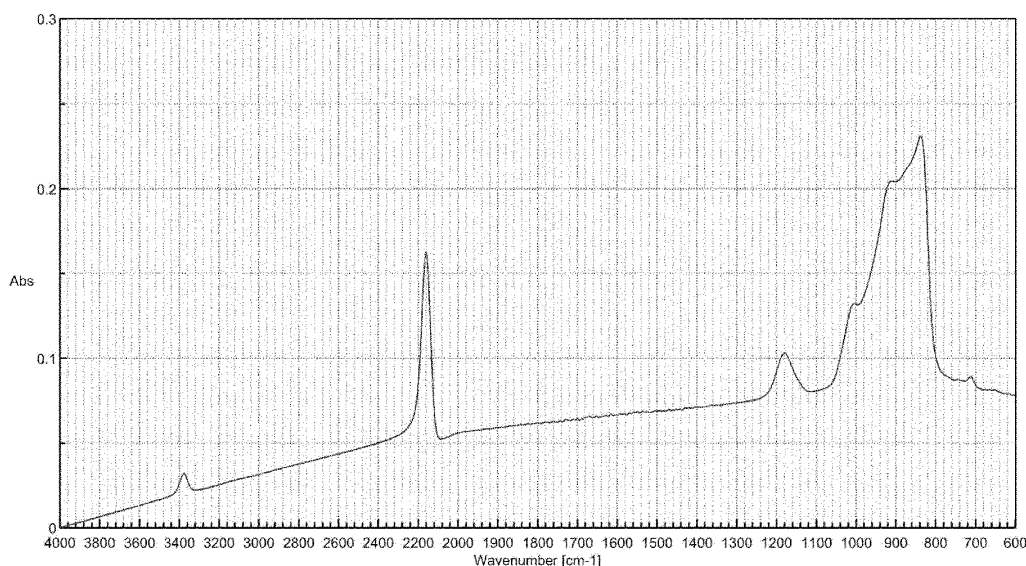


Figure 1

(57) Abstract: [Problem] To provide a polysilazane and a siliceous film-forming composition which can suppress film thickness variation and voids even in the ozone containing atmosphere. [Means for Solution] A polysilazane comprising N-Si bonds, wherein the ratio (NA^3/NA^2) of the number of N atoms having 3 N-Si bonds (NA^3) to the number of N atoms having 2 N-Si bonds (NA^2) is 1.8 to 6.0.

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